REMARKS

Original claims 1-35 are cancelled. Claims 36-51 are presented herein by this preliminary amendment. Support for the new claims is found throughout the specification and the amendment is otherwise proper. Support for claims 36-51 in the specification and claims, includes, but is not limited to, the following:

- Claim 36: Claims 1, 10, 20, and 21 as originally filed; page 11, line 25 through page 12, line 13, page 13, lines 23-26, and page 15, line 4 through page 17, line 7;
- Claim 37: Claims 1, 10, 20, and 21 as originally filed; page 11, line 25 through page 12, line 13, page 13, lines 23-26, and page 15, line 4 through page 17, line 7;
- Claim 38: Claim 22 as originally filed, page 11, line 25 through page 12, line 13, page 18, lines 19 and 31, page 19, line 10, page 24, line 7, page 26, line 8, and page 28, line 7, and page 31;
- Claim 39: Page 12, lines 9-14, and page 24, line 20;
- Claim 40: Claims 5 and 15 as originally filed; page 11, lines 1-2;
- Claim 41: Claims 5 and 15 as originally filed; page 11, lines 1-2;
- Claim 42: Claims 1 and 11 as originally filed; page 12, lines 15-17;
- Claim 43: Page 12, line 28 through page 13, line 10;
- Claim 44: Page 12, line 28 through page 13, line 10;
- Claim 45: Page 13, line 28 through page 13, lines 28-29;
- Claim 46: Page 13, line 28 through page 14, line 29;
- Claim 47: Page 14, lines 30-34;
- Claim 48: Claims 4 and 14 as originally filed, and page 15, lines 17-19;
- Claim 49: Claim 1 as originally filed, and page 15, line 32 through page 16, line 1;
- Claim 50: Claim 9 as originally filed, and page 15, line 32 through page 16, line 1; and
- Claim 51: Page 7, line 14 through page 8, line 23.

Entry of the foregoing amendment prior to examination is respectfully requested. Applicants believe that the preliminary amendment places the application in condition of allowance. Early notification of allowance is respectfully requested. If there should be any questions, personnel of the Patent and Trademark Office are invited to contact the undersigned at (262) 631-4495.

A marked up version of page 1 of the Specification reflecting the amendment in the Title and Cross-Reference to Related Applications, and the new claim set is included herewith.

Respectfully Submitted,

9/9/03

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MARKED UP SPECIFICATION (PAGE 1)

[HYPERBRANCHED POLYMERS] PROCESS FOR PRODUCING HYPERBRANCHED POLYMERS

Cross References to Related Applications

This application is a divisional of U.S. Serial No. 09/873,634, allowed, which is a continuation of U.S. Serial No. 09/389,821 filed September 3, 1999, now issued as U.S. Patent No. 6,265,511, which is a divisional of U.S. Serial No. 08/906,140 filed August 5, 1997, now issued as U.S. Patent No. 5,986,020.

MARKED UP VERSION OF CLAIMS

36. A continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product comprising:

- (a) continuously charging into a reactor monomers comprising divinylic monomers comprising at least one divinylic monomer and monoethylenically unsaturated monomers comprising at least one monoethylenically unsaturated monomer;
- (b) maintaining a level in the reactor such that the reactor is at least substantially filled; and
- (c) polymerizing the monomers to produce a polymeric product, wherein the polymeric product is formed substantially free of gel.
- 37. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the monomers comprise at least about 3% by weight of the divinylic monomers comprising at least one divinylic monomer and about 50% to about 97% by weight of the monoethylenically unsaturated monomers.
- 38. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 37, wherein the monomers comprise at least 6% by weight of the divinylic monomers and from about 50% to 94% by weight of the monoethylenically unsaturated monomers.
- 39. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 37, wherein the monomers comprise from 12% to about 30% by weight of the divinylic monomers.
- 40. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the divinylic monomers comprise divinyl benzene.

41. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the divinylic monomers consist of divinyl benzene.

- 42. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein (c) further comprises maintaining the temperature of the reactor at a temperature of from about 250°C to about 400°C.
- 43. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, further comprising adding a radical initiator to the reactor while the monomers are continuously charged into the reactor.
- 44. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 43, wherein the initiator is mixed with the monomers when the monomers are continuously charged into the reactor or the initiator is added to the reactor from a feed separate from the monomers.
- 45. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, further comprising adding a solvent to the reactor.
- 46. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 45, wherein the solvent is selected from the group consisting of n-hexane, toluene, propylene glycol monomethyl ether acetate, 2-ethyl-1-hexanol, 1-octanol, tripropylene glycol methyl ether, acetone, methyl iso-butyl carbinol, diethyleneglycol butyl ether, propylene glycol, tert-butyl ether, ethyl 3-ethoxypropionate, ethylene glycol monobutyl ether, ethylene glycol monomethyl ether acetate, 2-ethylhexyl acetate, diacetone alcohol, ethylene glycol 2-ethylhexyl ether, cyclohexanol, 2-ethyl-1-butanol, N-methyl-2-pyrrolidone, dipropylene glycol butyl ether, 2-methyl-1-butanol, 1-pentanol, diethylene glycol butyl ether acetate, diethylene glycol monomethyl ether, propylene

glycol monobutyl ether, benzyl alcohol, 1-methoxy-2-butanol, propylene glycol propyl ether, 2-methyl-1-pentanol, diethylene glycol monoethyl ether, ethylene glycol hexyl ether, sec-butanol, tert-amyl alcohol, phenol, tert-butanol, tripropylene glycol, ethylene glycol diacetate, dipropylene glycol methyl ether n-butanol, furfuryl alcohol, isobutanol, diethylene glycol monoethyl ether acetate, ethylene glycol monoethyl ether, diethylene glycol monopropyl ether, isopropanol, tetraethylene glycol, ethylene glycol propyl ether, n-propanol, ethylene glycol methyl ether, propylene glycol propyl ether, tetrahydrofurfuryl alcohol, acetonitrile, 2-phenoxyethanol, dimethyl sulfoxide, hexylene glycol, allyl alcohol, 2-pyrrolidinone, ethanol, triethylene glycol, and methanol.

- 47. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the monomers are in a mixture comprising the monomers and a surfactant or a chain transfer agent.
- 48. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the reactor is a continuous stirred tank reactor or a continuous loop reactor.
- 49. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein (c) further comprises maintaining a residence time of from about 2 minutes to about 60 minutes in the reactor.
- 50. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein (c) further comprises maintaining a residence time of from about 10 minutes to about 20 minutes in the reactor.
- 51. The continuous, high temperature polymerization process for preparing a substantially gel-free polymerized polymeric product according to claim 36, wherein the at least one monoethylenically unsaturated monomer is selected from the group consisting of styrene, α-methylstyrene, vinyl toluene, 4-methylstyrene, tertbutylstyrene, 2-chlorostyrene, vinylpyridine,

vinylpyrrolidone, maleic anhydride, methyl crotonoate, sodium crotonoate, acrylic acid and its salts, methyl acrylate, ethyl acrylate, propyl acrylate, isopropyl acrylate, butyl acrylate, 2ethylhexyl acrylate, decyl acrylate, hydroxyethyl acrylate, hydroxypropyl acrylate, methacrylic acid and its salts, methyl methacrylate, ethyl methacrylate, propyl methacrylate, hydroxypropyl methacrylate, isopropyl methacrylate, butyl methacrylate, sec-butyl methacrylate, isobutyl methacrylate, n-amyl methacrylate, isoamyl methacrylate, n-hexyl methacrylate, tert-butyl methacrylate, 2-ethylhexyl methacrylate, n-octyl methacrylate, methallyl methacrylate, phenyl methacrylate, benzyl methacrylate, allyl methacrylate, cyclohexyl methacrylate, 2-hydroxyethyl methacrylate, 2-hydroxypropyl methacrylate, N,N-dimethylaminoethyl methacrylate, N,Ndiethylaminoethyl methacrylate, tert-butylaminoethyl methacrylate, 2-sulfoethyl methacrylate, trifluoroethyl methacrylate, glycidyl methacrylate, 2-n-butoxyethyl methacrylate, 2-chloroethyl methacrylate, 2 - ethylbutyl methacrylate, cinnamyl methacrylate, cyclopentyl methacrylate, 2ethoxyethyl methacrylate, furfuryl methacrylate, hexafluoroisopropyl methacrylate, 3methoxybutyl methacrylate, 2-methoxybutyl methacrylate, 2-nitro-2-methylpropyl methacrylate, 2-phenoxyethyl methacrylate, 2-phenylethyl methacrylate, propargyl methacrylate, tetrahydrofurfuryl methacrylate, tetrahydropyranyl methacrylate, methacrylamide, Nmethylmethacrylamide, N-ethylmethacrylamide, N,N-diethylmethacrylamide, N,Ndimethylmethacrylamide, N-phenylmethacrylamide, acrylamide, N,N-diethylacrylamide, Nethylacrylamide, methyl 2-cyanoacrylate, methyl alpha-chloroacrylate, methacrolein, acrolein, methacrylonitrile, acrylonitrile, and mixtures thereof.